

Docket No. 210136US99



AP

152812
X

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF: Ravindranath DROOPAD et al.

SERIAL NO: 09/901,109

GAU: 2812

FILED: July 10, 2001

EXAMINER: BOOTH, R.A.

FOR: STRUCTURE AND METHOD FOR FABRICATING SEMICONDUCTOR STRUCTURES AND DEVICES UTILIZING THE FORMATION OF A COMPLIANT SUBSTRATE COMPRISING AN OXYGEN-DOPED COMPOUND SEMICONDUCTOR LAYER

EXPRESS ABANDONMENT UNDER 37 CFR 1.138

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313

SIR:

Applicant(s) wish to disclose the following information.

☒ **Express Abandonment**

Applicant's Representative requests that the above-identified application be expressly abandoned as of the filing date of this paper.

☐ **Express Abandonment in Favor of a Continuing Application**

Applicant's Representative requests that the above-identified application be expressly abandoned as of the filing date accorded the continuing application filed herewith.

☐ **Petition for Express Abandonment to Avoid Publication under 37 C.F.R. 1.138(c)**

Applicant's Representative hereby petitions to expressly abandon the above-identified application under 37 CFR 1.138(c) to avoid publication.

The required petition fee under 37 CFR 1.17(h) of \$130.00 is enclosed herewith by credit card payment form and any further charges may be made against the Attorney of Record's Deposit Account No. 15-0030. A duplicate copy of this sheet is enclosed.

11/31/2006 HBEYENE2 00000051 09901109

11 FC:1464

130.00 OP

Respectfully submitted,

OBLON, SPIVAK, McCLELLAND,
MAIER & NEUSTADT, P.C.

Richard L. Treanor

Registration No. 36,379

Customer Number

22850

Tel. (703) 413-3000
Fax. (703) 413-2220
(OSMMN 05/03)

Adjustment date: 05/09/2006 SDIRETA1
01731/2006 HBEYENE2 00000051 09901109
01 FC:1464 -130.00 OP

Refund Ref: 0030031336
05/09/2006

Credit Card Refund Total: \$130.00

Am Exp.: XXXXXXXXXXXX1008



DOCKET NO: 210136US99

Dep't Ref

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

RE APPLICATION OF

RAVINDRANATH DROOPAD ET AL.

: EXAMINER: BOOTH, R.A.

SERIAL NO: 09/901,109

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FILED: JULY 10, 2001

: GROUP ART UNIT: 2812

FOR: STRUCTURE AND METHOD FOR
FABRICATING SEMICONDUCTOR
STRUCTURES AND DEVICES
UTILIZING THE FORMATION OF A
COMPLIANT SUBSTRATE COMPRISING
AN OXYGEN-DOPED COMPOUND
SEMICONDUCTOR LAYER

REQUEST FOR REFUND

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313

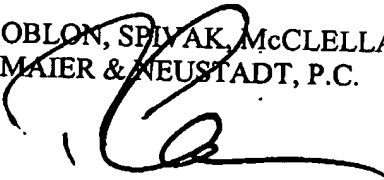
SIR:

Applicants request a refund in the amount of \$130.00 for the Express Abandonment Under 37 CFR 1.138 fee paid in error on January 30, 2006, in the above-identified application. Applicants request a refund as the fee is only required with a petition to avoid publication of the application.

Please credit the refund to our Deposit Account No. 15-0030. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

OBLON, SPIVAK, McCLELLAND,
MAIER & NEUSTADT, P.C.


Richard L. Treanor
Attorney of Record
Registration No. 36,379

Customer Number
22850

Tel: (703) 413-3000
Fax: (703) 413-2220
(USPTO 06/01)

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